

Manish Chhowalla is a Professor, Associate Chair of the Materials Science and Engineering Department, and the Director of the Institute for Advanced Materials, Devices and Nanotechnology at Rutgers University. From June 2009 – July 2010, he was a Professor in the Department of Materials at Imperial College London. Before Rutgers, he was a Royal Academy of Engineering Postdoctoral Research Fellow at the University of Cambridge after completing his Ph.D. in Electrical Engineering there. Prior to his PhD, he worked for Multi-Arc Inc. (now Ion Bond) where he developed one of the first applications of “amorphous diamond” thin films. He is a Fellow of the Royal Society of Chemistry and Institute of Physics. He is also the Editor in Chief of Applied Materials Today. His current interests are in the fundamental studies of 2D materials.